



CVD TUBE FURNACES

CVD Tube Furnaces

CVD (Chemical Vapor Deposition) Tube Furnaces are engineered for precise control of temperature and gas flow in thin-film deposition processes. Ideal for synthesizing materials like graphene, carbon nanotubes, and semiconductor coatings, these furnaces support both low-pressure and atmospheric CVD. With uniform heating zones and robust sealing for vacuum or inert atmospheres, they offer reliable performance for advanced material research and development.



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